CLAIMS:

1. Method for manufacturing a light emitting display on a substrate comprising the steps of:
- depositing a first electrode layer on or over said substrate;
- forming a plurality of light emitting layer segments on or over at least a part of said first electrode layer;
- applying at least one protective layer on or over at least one of said light emitting layer segments;
- depositing a second electrode layer.

2. Method according to claim 1, wherein said first electrode layer is deposited on or over said substrate and comprises a material transparent to the light to be emitted by said light emitting layer segments in operation of the light emitting display.

3. Method according to claim 1, wherein said protective layer comprises molybdenum or titanium.

4. Method according to claim 1, wherein said second electrode layer is patterned by applying photolithography and subsequent etching in correspondence to said light emitting layer segments.

5. Method according to claim 4, wherein said second electrode layer is patterned such that it comprises recesses outside the areas comprising said light emitting layer segments, beneath which recesses said protective layer is substantially removed.

6. Method according to claim 5 wherein said patterned second electrode layer and said recesses are covered by at least one sealing film.

7. Method according to claim 1, wherein said second electrode layer has a thickness larger than 0.5μm and preferably between 0.5μm and 3μm.

8. Light emitting display comprising:

- a substrate;
- a first electrode layer deposited on or over said substrate;
- a plurality of light emitting layer segments formed on or over said first electrode layer;
- at least one protective layer applied on or over at least some of said light emitting layer segments;
- a second electrode layer.

9. Light emitting display according to claim 8, wherein said protective layer comprises molybdenum or titanium.

10. Light emitting display according to claim 8, wherein said second electrode layer has a thickness between 0.5μm and 3μm.

11. Light emitting display according to claim 8, wherein said second electrode layer is patterned in correspondence with said light emitting layer segments and said patterned second electrode layer is covered by at least one sealing film.

12. Electric device comprising a light emitting display according to one of the claims 8-11 and/or manufactured according one of the claim 1-7.